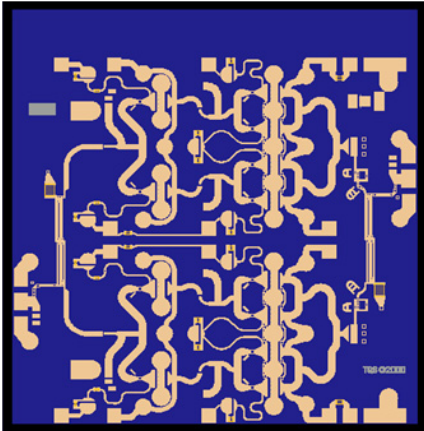


**Q Band Power Amplifier**



**Key Features**

- Frequency Range: 40-45 GHz
- 29 dBm Nominal Pout @ P1dB
- 10 dB Nominal Gain
- 0.25 um pHEMT Technology
- Bias 7V @ 500 mA
- Chip Dimensions 3.08 mm x 3.14 x 0.10 mm (0.121 x 0.124 x 0.004 in)

**Primary Applications**

- Point to Point Radio
- Point to Multipoint Radio
- Military Communications

**Product Description**

The TriQuint TGA4043 is a compact High Power Amplifier MMIC for Q-band applications. The part is designed using TriQuint's proven standard 0.25 um gate power pHEMT production process.

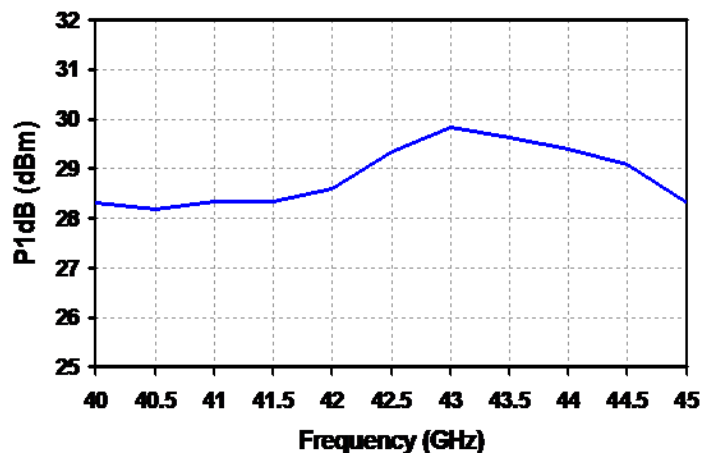
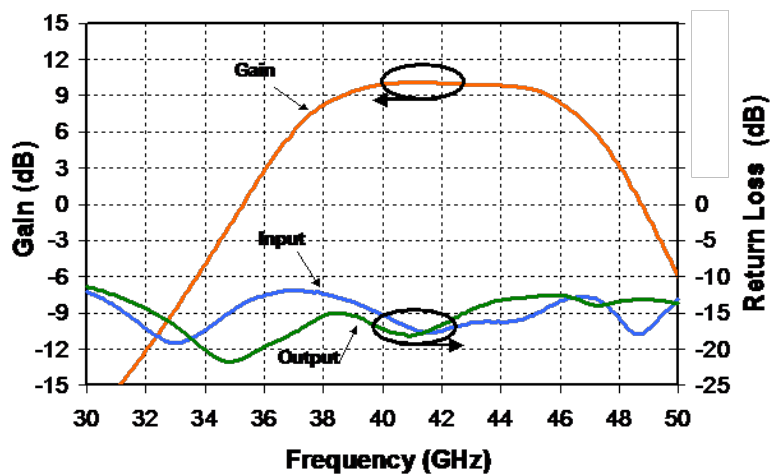
The TGA4043 provides a nominal 28 dBm of output power at 1 dB gain compression from 40-45 GHz with a small signal gain of 10 dB.

The part is ideally suited for low cost emerging markets such as Point-to-Point Radio and Point-to-Multi Point Communications.

The TGA4043 is 100% DC and RF tested on-wafer to ensure performance compliance.

**Measured Fixtured Data**

Bias Conditions: Vd = 7V, Id = 500mA



**TABLE I**  
**MAXIMUM RATINGS 1/**

SYMBOL	PARAMETER	VALUE	NOTES
V <sup>+</sup>	Positive Supply Voltage	8 V	<u>2/</u>
V <sup>-</sup>	Negative Supply Voltage Range	-5V TO 0V	
I <sup>+</sup>	Positive Supply Current	960 mA	<u>2/</u>
I <sub>G</sub>	Gate Supply Current	56 mA	
P <sub>IN</sub>	Input Continuous Wave Power	27 dBm	<u>2/</u>
P <sub>D</sub>	Power Dissipation	7.5 W	<u>2/</u> , <u>3/</u>
T <sub>CH</sub>	Operating Channel Temperature	200 °C	<u>4/</u> , <u>5/</u>
	Mounting Temperature (30 Seconds)	320 °C	
T <sub>STG</sub>	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Current is defined under no RF drive conditions. Combinations of supply voltage, supply current, input power, and output power shall not exceed P<sub>D</sub>.
- 3/ When operated at this power dissipation with a base plate temperature of 70 °C, the median life is 7.3E3 hours.
- 4/ Junction operating temperature will directly affect the device median time to failure (T<sub>m</sub>). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 5/ These ratings apply to each individual FET.

**TABLE II**  
**DC PROBE TEST**  
 (T<sub>A</sub> = 25 °C, Nominal)

SYMBOL	PARAMETER	MINIMUM	MAXIMUM	UNIT
I <sub>dss, Q1</sub>	Saturated Drain Current	40	188	mA
G <sub>m, Q1</sub>	Transconductance	88	212	mS
V <sub>p, Q1,2, 3-6, 7, 8, 9-12</sub>	Pinch-off Voltage	-1.5	-0.5	V
V <sub>BVGD, Q1,2</sub>	Breakdown Voltage Gate-Drain	-30	-8	V
V <sub>BVGS, Q1</sub>	Breakdown Voltage Gate-Source	-30	-8	V

**TABLE III**  
**RF CHARACTERIZATION TABLE**

(T<sub>A</sub> = 25 °C, Nominal)  
 V<sub>d</sub> = 7V, I<sub>d</sub> = 500 mA

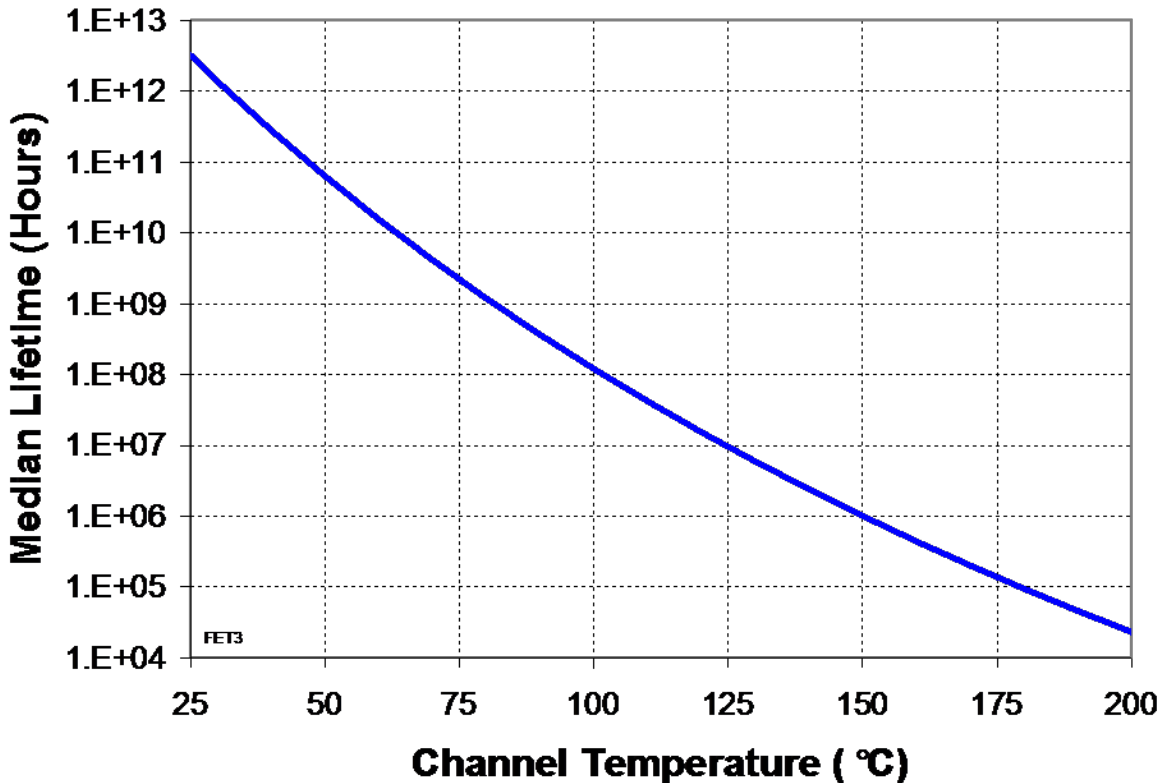
<b>SYMBOL</b>	<b>PARAMETER</b>	<b>TEST CONDITION</b>	<b>TYPICAL LIMITS</b>	<b>UNITS</b>
Gain	Small Signal Gain	F = 40-45 GHz	10	dB
IRL	Input Return Loss	F = 40-45 GHz	14.5	dB
ORL	Output Return Loss	F = 40-45 GHz	12.5	dB
P <sub>1dB</sub>	Output Power @ 1dB Gain Compression	F = 40-45 GHz	29	dBm

**TABLE IV**  
**THERMAL INFORMATION**

Parameter	Test Conditions	T <sub>CH</sub> (°C)	θ <sub>JC</sub> (°C/W)	T <sub>m</sub> (HRS)
θ <sub>JC</sub> Thermal Resistance (channel to backside of carrier)	V <sub>d</sub> = 7 V I <sub>D</sub> = 500 mA P <sub>diss</sub> = 3.5 W	130	17.3	5.9 E+6

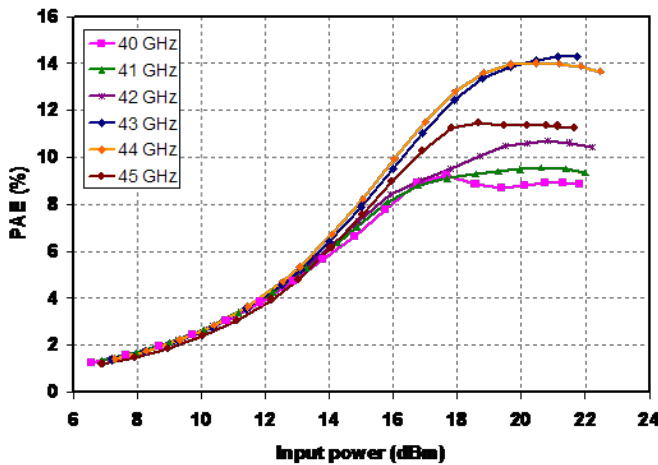
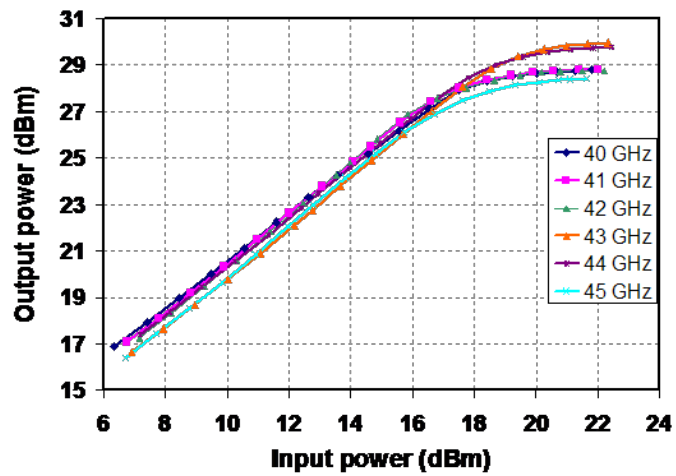
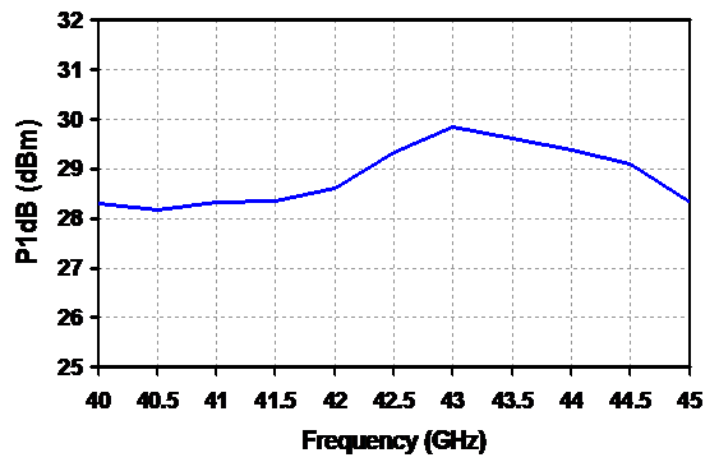
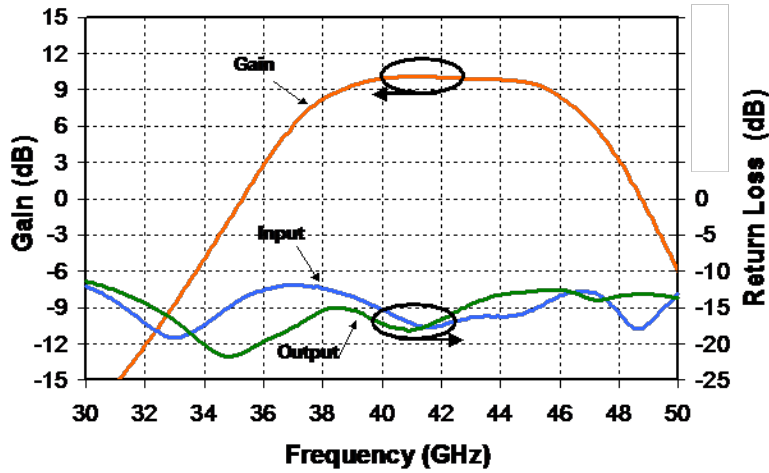
Note: Assumes eutectic attach using 1.5 mil 80/20 AuSn mounted to a 20 mil CuMo Carrier at 70 °C baseplate temperature. Worst case condition with no RF applied, 100% of DC power is dissipated.

**Median Lifetime (T<sub>m</sub>) vs. Channel Temperature**

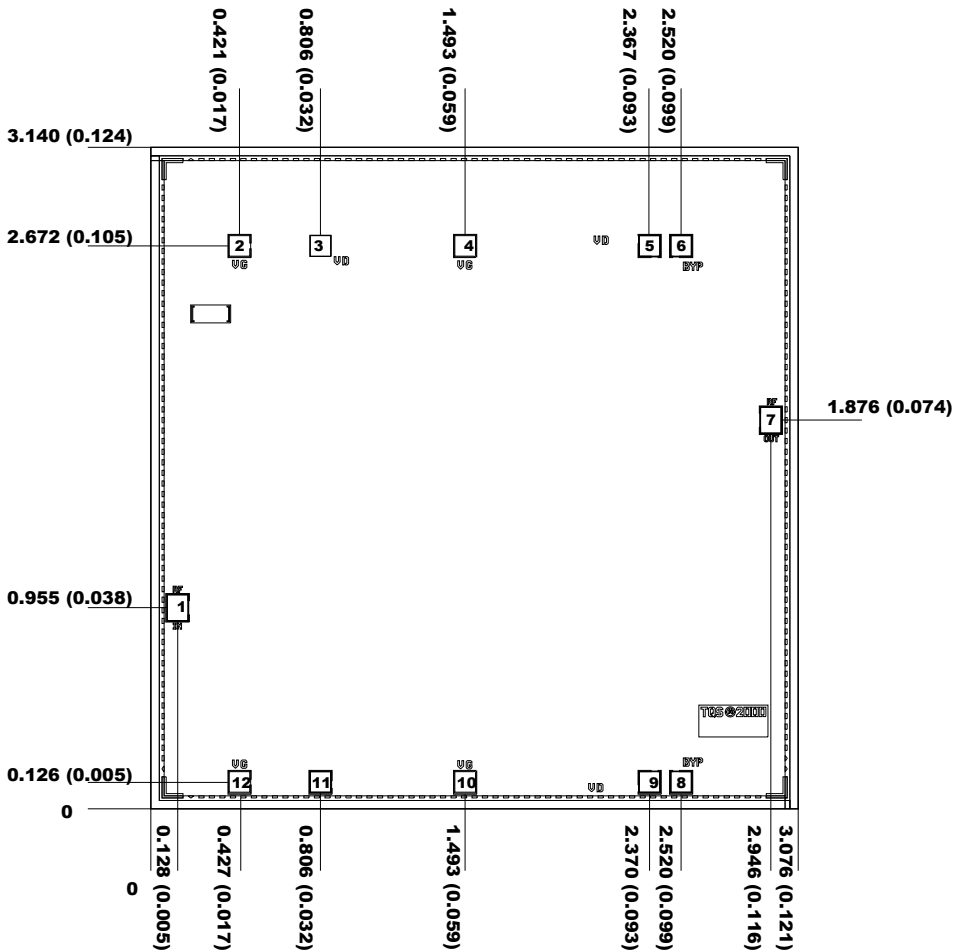


**Measured Fixtured Data**

Bias Conditions:  $V_d = 7V$ ,  $I_d = 500mA$



Mechanical Characteristics



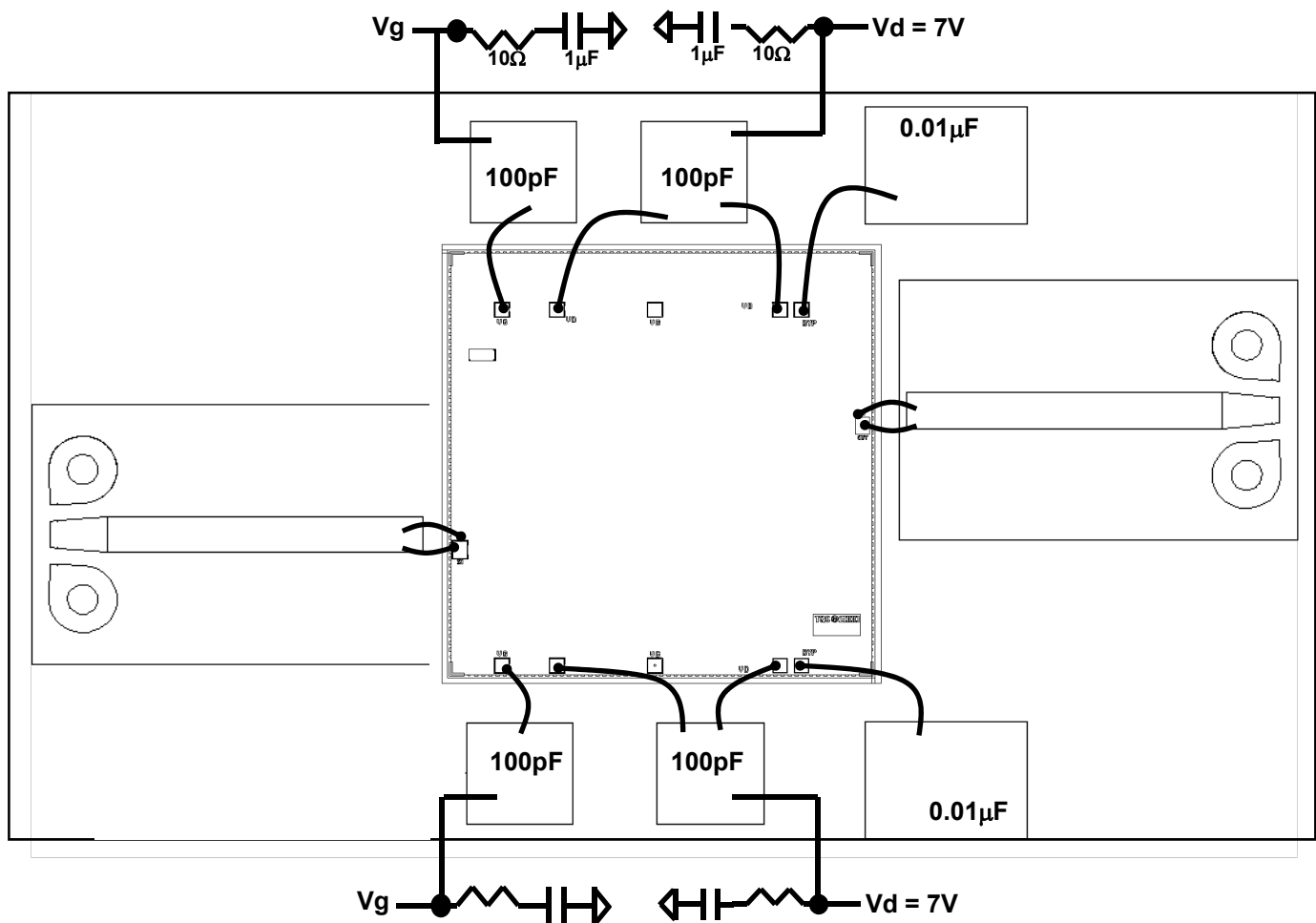
Units: millimeters (inches)  
 Thickness: 0.100 (0.004) (reference only)  
 Chip edge to bond pad dimensions are shown to center of bond pad  
 Chip size tolerance: +/- 0.051 (0.002)

**GND IS BACKSIDE OF MMIC**

<b>Bond Pad #1 (RF Input)</b>	<b>0.105 x 0.130 (0.004 x 0.005)</b>
<b>Bond Pad #2 (Vg 1)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #3 (Vd 1)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #4 (Vg 1)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #5 (Vd 1)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #6 (Bypass)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #7 (RF Output)</b>	<b>0.105 x 0.130 (0.004 x 0.005)</b>
<b>Bond Pad #8 (Bypass)</b>	<b>0.105 x 0.130 (0.004 x 0.005)</b>
<b>Bond Pad #9 (Vd 2)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #10 (Vg 2)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #11 (Vd #2)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>
<b>Bond Pad #12 (Vg #2)</b>	<b>0.105 x 0.105 (0.004 x 0.004)</b>

*GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.*

Recommended Assembly Diagram



Note:

We recommend 1µF caps on the bias lines to suppress possible low frequency oscillations.

**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**

## Assembly Process Notes

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300 °C for 30 sec
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.
- Maximum stage temperature is 200 °C.

***GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.***